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APPENDICES

The Joint Committee for Powder Diffraction Standards (JCPDS) [78]

1. ZnTe, JCPDS file number 15-0746

Name and formula

Reference code:	15-0746	Empirical formula:	TeZn
PDF index name:	Zinc Telluride	Chemical formula:	ZnTe

Crystallographic parameters

Crystal system:	Cubic	Alpha (degree):	90.0000
Space group:	F-43m	Beta (degree):	90.0000
Space group number:	216	Gamma (degree):	90.0000
a (Å):	6.1026	Calculated density:	5.37
b (Å):	6.1026	Volume of cell:	227.27
c (Å):	6.1026	Z:	4.00
		RIR:	9.30

Subfiles and Quality

Subfiles: Inorganic Alloy, metal or intermetalic Common Phase

Educational pattern, NBS pattern

Quality: Star (S)

Comments

Color: Reddish brown

Sample source: Sample was obtained from Semi-Elements, Inc.,

Saxonburg, Pennsylvania, USA.

Analysis: Spectrographic analysis: 0.01-0.1% of Si; 0.001-0.01%

each of Al, Ba, Fe, and Mg.

Temperature: Pattern taken at 25 C.

References

Primary reference: *Natl. Bur. Stand. (U.S.) Monogr. 25, 3, 58, (1964)*

Peak list

No.	h	k	l	d [A]	I [%]	No.	h	k	l	d [A]	I [%]
1	1	1	1	3.52300	100.0	11	4	4	0	1.07890	4.0
2	2	0	0	3.05100	10.0	12	5	3	1	1.03150	6.0
3	2	2	0	2.15900	80.0	13	6	0	0	1.01710	2.0
4	3	1	1	1.84000	35.0	14	6	2	0	0.96480	6.0
5	2	2	2	1.76200	4.0	15	5	3	3	0.93070	4.0
6	4	0	0	1.52600	8.0	16	6	2	2	0.92000	2.0
7	3	3	1	1.40030	14.0	17	4	4	4	0.88080	2.0
8	4	2	0	1.36450	4.0	18	5	5	1	0.85450	6.0
9	4	2	2	1.24560	10.0	19	6	4	2	0.81550	8.0
10	5	1	1	1.17450	8.0	20	7	3	1	0.79450	6.0

Stick Pattern

Ref. Pattern: Zinc Telluride, 15-0746
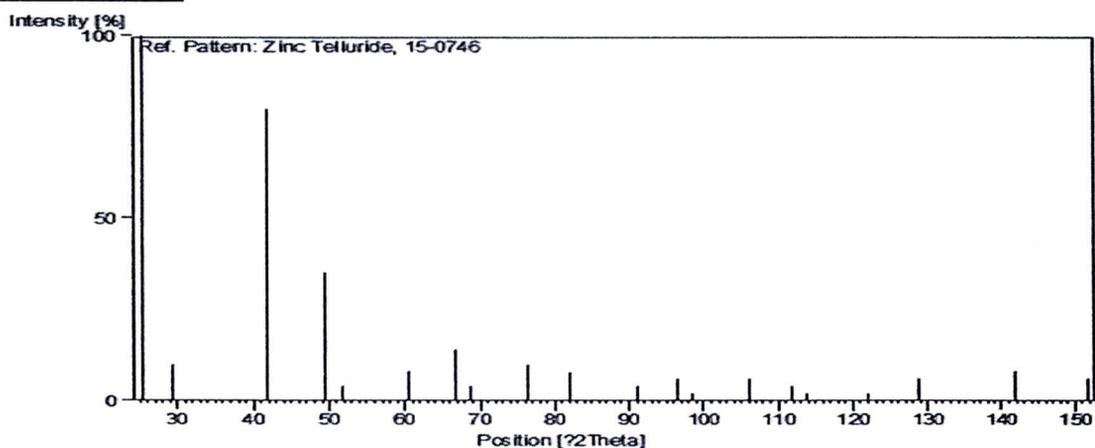
2. Zn, JCPDS file number 01-1238

Name and formula

Reference code:	01-1238	Empirical formula:	Zn
PDF index name:	Zinc	Chemical formula:	Zn

Crystallographic parameters

Crystal system:	Hexagonal	Alpha (degree):	90.0000
Space group:	P63/mmc	Beta (degree):	90.0000
Space group number:	194	Gamma (degree):	120.0000
a (Å):	2.6591	Measured density:	7.10
b (Å):	2.6591	Volume of cell:	30.22
c (Å):	4.9353	Z:	2.00
		RIR:	-

Status, subfiles and quality

Status:	Marked as deleted by ICDD
Subfiles:	Inorganic
Quality:	Blank (B)

Comments

Deleted by:	Deleted by NBS card.
Color:	White
Melting point:	420

References

Primary reference:	Hanawalt et al., *Anal. Chem.*, **10**, 475, (1938)
Unit cell:	*Dana's System of Mineralogy, 7th Ed.*

Peak list

No.	h	k	l	d [A]	I [%]
1	0	0	2	2.46000	25.0
2	1	0	0	2.30000	20.0
3	1	0	1	2.08000	100.0
4	1	0	2	1.68000	14.0
5	1	1	0	1.33000	18.0

No.	h	k	l	d [A]	I [%]
6	1	1	2	1.17000	12.0
7	2	0	1	1.12000	8.0
8	2	0	2	1.04000	2.0
9	2	0	3	0.94000	2.0
10	1	0	5	0.91000	2.0

Stick Pattern

Ref. Pattern: Zinc, 01-1238
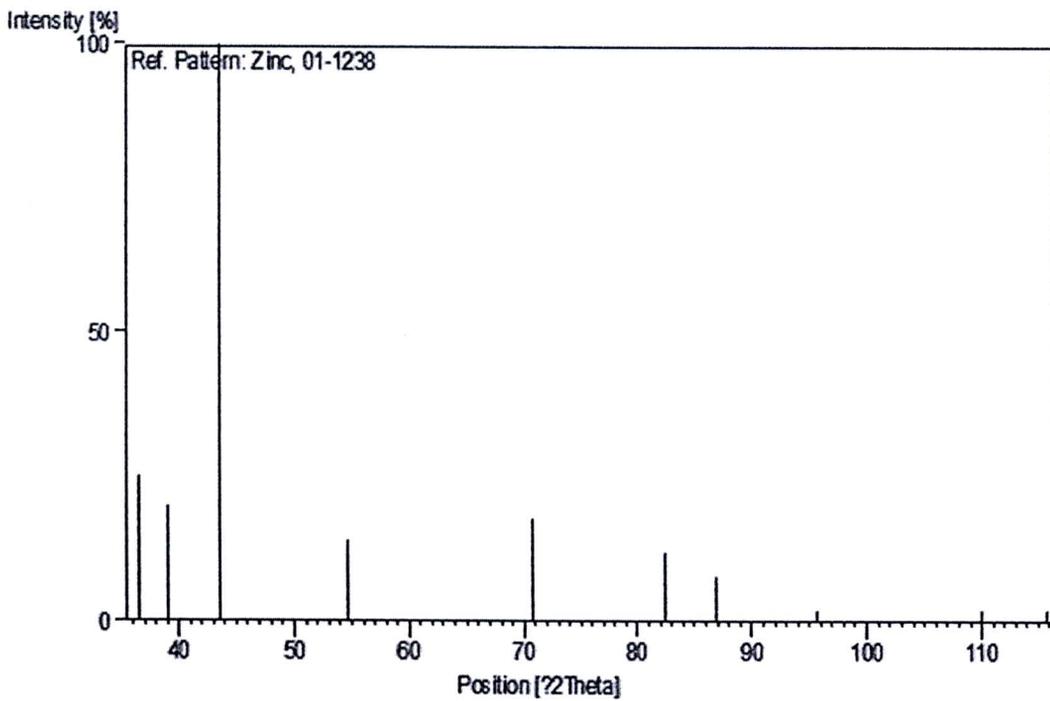
3. Te, JCPDS file number 01-0714

Name and formula

Reference code:	01-0714	Empirical formula:	Te
PDF index name:	Tellurium	Chemical formula:	Te

Crystallographic parameters

Crystal system:	Hexagonal	Alpha (degree):	90.0000
Space group:	P312	Beta (degree):	90.0000
Space group number:	149	Gamma (degree):	120.0000
a (Å):	4.4450	Measured density:	6.20
b (Å):	4.4450	Volume of cell:	101.13
c (Å):	5.9100	Z:	3.00
		RIR:	-

Status, subfiles and quality

Status:	Marked as deleted by ICDD
Subfiles:	Inorganic
Quality:	Blank (B)

Comments

Color:	Silvery
Optical data:	B=2.68, Q=3.07, Sign=+
Melting point:	449.8

References

Primary reference:	Hanawalt. et al., *Anal. Chem.*, **10**, 475, (1938)
Unit cell:	*Dana's System of Mineralogy, 7th Ed.*

Peak list

No.	h	k	l	d [A]	I [%]	No.	h	k	l	d [A]	I [%]
1	0	0	1	5.80000	19.0	11	1	1	3	1.47000	28.0
2	1	0	0	3.86000	14.0	12	2	1	1	1.42000	13.0
3	1	0	1	3.24000	100.0	13	1	0	4	1.38000	16.0
4	1	0	2	2.34000	48.0	14	2	1	2	1.31000	8.0
5	1	1	0	2.22000	32.0	15	3	0	1	1.26000	5.0
6	1	1	1	2.08000	14.0	16	0	0	5	1.18000	14.0
7	0	0	3	1.96000	14.0	17	2	2	0	1.12000	5.0
8	2	0	1	1.83000	28.0	18	3	1	1	1.05000	5.0
9	1	1	2	1.77000	10.0	19	2	0	5	1.01000	5.0
10	2	0	2	1.61000	20.0	20	3	0	4	0.97000	2.0
						21	3	0	5	0.87000	2.0

Stick Pattern
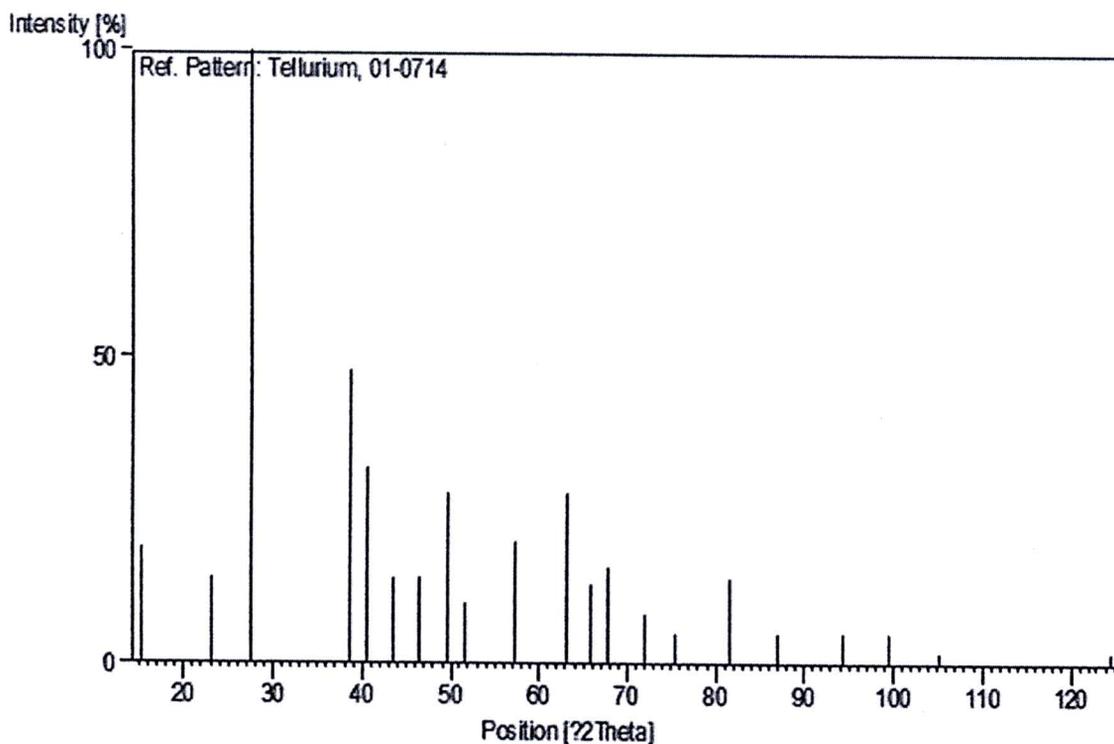
4. Te, JCPDS file number 36-1452

Name and formula

Reference code:	36-1452	Empirical formula:	Te
PDF index name:	Telluride	Chemical formula:	Te

Crystallographic parameters

Crystal system:	Hexagonal	Alpha (degree):	90.0000
Space group:	P3121	Beta (degree):	90.0000
Space group number:	152	Gamma (degree):	120.0000
a (Å):	4.4579	Calculated density:	6.23
b (Å):	4.4579	Volume of cell:	102.01
c (Å):	5.9270	Z:	3.00
		RIR:	-

Status, subfiles and quality

Status: -

Subfiles: Inorganic, Mineral, Alloy, Metal or Intermetalic, Common Phase, Educational pattern, Forensic, NBS pattern

Quality: Star (S)

Comments

Color: Gray metallic

General comments: The structure was determined by Bradley (1).

Hexagonal close packed.

Color values in air C illuminant: x .311 .308, y .318 .317, Y% 59.9 69.4, ld 560 495, Pe% 0.7 0.6.

QDF-2.

On synthetic material.

Sample source:	The sample was from the Fisher Scientific Co., Fair Lawn, NJ, USA. It was ground and annealed at 300 C for 1/2 hour.
Polymorphism:	There are several high pressure polymorphs of tellurium.
Additional pattern:	To replace 4-554 (2).
Temperature:	The mean temperature of data collection was 25.41 °C.

References

Primary reference:	McMurdie, H., Morris, M., Evans, E., Paretzkin, B., Wong-Ng, W., Ettlinger, L., Hubbard, C., Powder Diffraction, 1, 76, (1986)
Structure:	1. Bradley, A., Philos. Mag., 48, 477, (1924)
Additional pattern:	2. Swanson, H., Tatge, E., Natl. Bur. Stand. (U.S.), Circ. 539, 1, 26, (1953)

Peak list

No.	h	k	l	d [A]	I [%]	No.	h	k	l	d [A]	I [%]
1	1	0	0	3.85643	16.0	5	1	1	1	2.08643	8.0
2	1	0	1	3.23356	100.0	6	0	0	3	1.97545	9.0
3	1	0	2	2.35047	36.0	7	2	0	0	1.93001	3.0
4	1	1	0	2.22839	25.0	8	2	0	1	1.83540	14.0

No.	h	k	l	d [A]	I [%]		No.	h	k	l	d [A]	I [%]
9	1	1	2	1.78135	4.0		22	2	0	4	1.17513	4.0
10	1	0	3	1.75904	2.0		23	2	1	3	1.17387	3.0
11	2	0	2	1.61752	8.0		24	1	0	5	1.13299	1.0
12	1	1	3	1.47824	7.0		25	2	2	0	1.11467	1.0
13	2	1	0	1.45865	5.0		26	2	2	1	1.09532	1.0
14	2	1	1	1.41652	4.0		27	3	0	3	1.07832	1.0
15	1	0	4	1.38363	4.0		28	3	1	0	1.07084	1.0
16	2	0	3	1.38110	4.0		29	3	1	1	1.05346	1.0
17	2	1	2	1.30906	3.0		30	1	1	5	1.04680	1.0
18	3	0	0	1.28698	1.0		31	2	2	2	1.04337	1.0
19	3	0	1	1.25767	2.0		32	2	1	4	1.03962	1.0
20	1	1	4	1.23411	1.0		33	2	0	5	1.01005	1.0
21	3	0	2	1.18030	1.0		34	3	1	2	1.00708	1.0

Stick Pattern
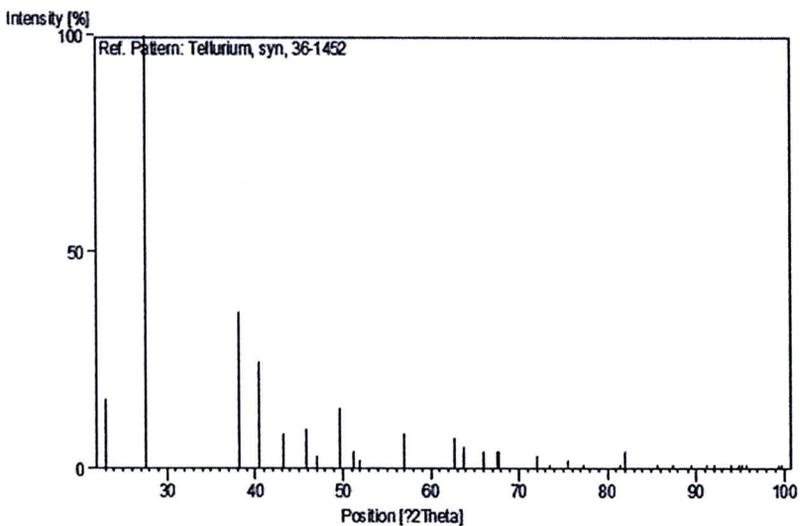
5. Sb$_2$Te$_3$, JCPDS file number 15-0874

Name and formula

Reference code:	15-0874	Empirical formula:	Sb$_2$Te$_3$
PDF index name:	Antimony Telluride	Chemical formula:	Sb$_2$Te$_3$

Crystallographic parameters

Crystal system:	Rhombohedral	Alpha (degree):	90.0000
Space group:	R-3M	Beta (degree):	90.0000
Space group number:	166	Gamma (degree):	120.0000
a (Å):	4.2620	Calculated density:	6.51
b (Å):	4.2620	Volume of cell:	479.01
c (Å):	30.4500	Z:	3.00
		RIR:	-

Status, subfiles and quality

Status:	-
Subfiles:	Inorganic, Mineral, Alloy, Metal or Intermetalic
Quality:	Indexed (I)

Comments

Color:	Dark gray
General comments:	Mineral occurs at Mattagami Lake mine, Galinee Twp., Quebec, Canada, Thorpe, R. et al., Can. Mineral., 12 55 (1973).
Sample source:	Sample was obtained from Semitronics, Inc., Winchester, Massachusetts, USA.

Sample preparation: The sample was heated overnight in an evacuated tube.

Analysis: Spectroscopic analysis: 0.001 to 0.01% each of Al and Si.

Unit cell: Rhombohedral cell: a=10.444, a=23.55.

Temperature: Pattern taken at 25 °C.

References

Primary reference: Natl. Bur. Stand. (U.S.) Monogr. 25, 3, 8, (1964)

Unit cell: Am. Mineral., 59, 383, (1974)

Peak list

No.	h	k	l	d [A]	I [%]	No.	h	k	l	d [A]	I [%]
1	0	0	3	10.16000	2.0	15	1	1	9	1.80400	2.0
2	0	0	6	5.08000	4.0	16	2	0	5	1.76600	10.0
3	0	0	9	3.38300	6.0	17	0	0	18	1.69200	2.0
4	1	0	4	3.32100	2.0	18	2	0	8	1.66100	1.0
5	0	1	5	3.15700	100.0	19	0	1	17	1.61100	2.0
6	1	0	7	2.81500	1.0	20	0	2	10	1.57800	8.0
7	0	1	8	2.65100	2.0	21	2	0	11	1.53700	2.0
8	1	0	10	2.34900	35.0	22	1	0	19	1.47000	8.0
9	0	1	11	2.21500	6.0	23	0	0	21	1.45000	2.0
10	1	1	0	2.13000	25.0	24	0	1	20	1.40800	2.0
11	0	0	15	2.03000	4.0	25	1	2	5	1.35970	8.0
12	1	0	13	1.97700	4.0	26	0	2	16	1.32490	2.0
13	1	1	6	1.96400	2.0	27	2	1	10	1.26830	6.0
14	0	1	14	1.87500	4.0	28	0	1	23	1.24620	2.0

No.	h	k	l	d [A]	I [%]		No.	h	k	l	d [A]	I [%]
29	3	0	0	1.23030	2.0		37	3	0	15	1.05220	1.0
30	0	2	19	1.21020	2.0		38	1	0	28	1.04310	1.0
31	1	1	21	1.19880	1.0		39	1	2	20	1.02860	1.0
32	1	2	14	1.17420	2.0		40	0	2	25	1.01670	1.0
33	3	0	9	1.15630	1.0		41	0	1	29	1.00960	1.0
34	2	1	16	1.12520	1.0		42	3	0	18	0.99520	1.0
35	2	0	23	1.07590	1.0		43	1	3	10	0.97040	1.0
36	2	2	0	1.06550	2.0		44	2	2	15	0.94340	1.0

Stick Pattern

Ref. Pattern: Tellurantimony, syn, 15-0874
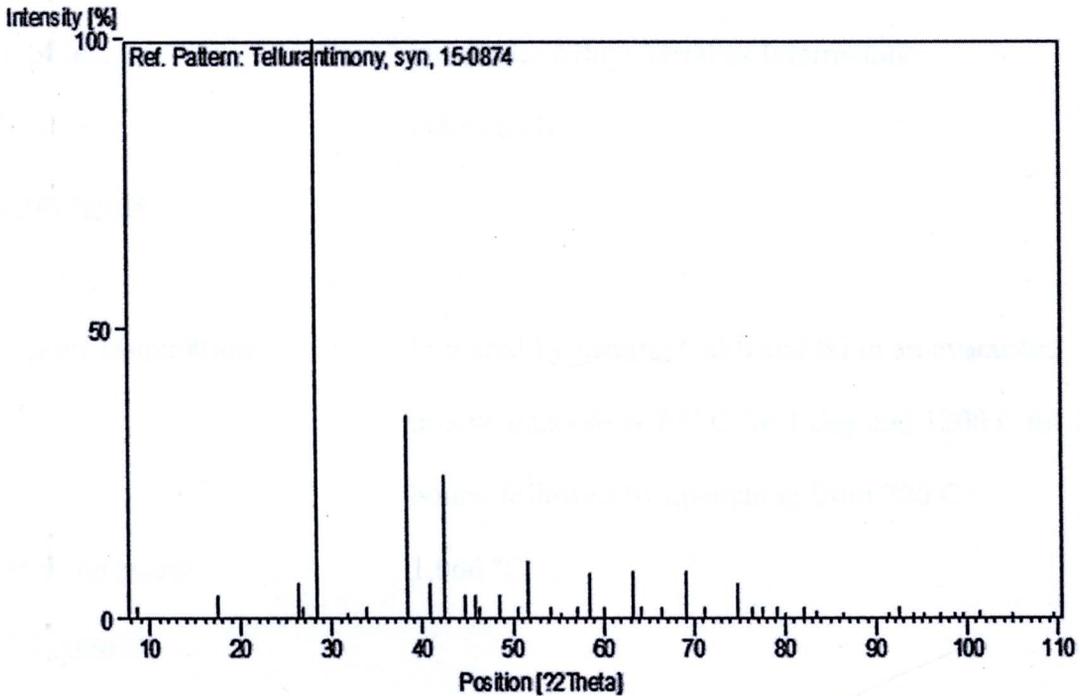
6. Ni₃GaSb, JCPDS file number 47-1401

Name and formula

Reference code:	47-1401	Empirical formula:	Ni_3GaSb
PDF index name:		Chemical formula:	Ni_3GaSb

Antimony Gallium Nickel

Crystallographic parameters

Crystal system:	Hexagonal	Alpha (degree):	90.0000
Space group:	P63/mmc	Beta (degree):	90.0000
Space group number:	194	Gamma (degree):	120.0000
a (Å):	4.0000	Measured density:	-
b (Å):	4.0000	Volume of cell:	70.53
c (Å):	5.0900	Z:	1.00
		RIR:	-

Status, subfiles and quality

Subfiles:	Inorganic, Alloy, Metal or Intermetalic
Quality:	Indexed (I)

Comments

Color:	-
Sample preparation:	Prepared by heating GaSb and Ni in an evacuated quartz ampoule at 700 C for 1 day and 1200 C for 2 hours, followed by quenching from 700 C.
Melting point:	1,066 °C

References

Peak list

No.	h	k	l	d [A]	I [%]		No.	h	k	l	d [A]	I [%]
1	1	0	1	2.86600	76.0		7	1	0	3	1.52300	12.0
2	0	0	2	2.54800	12.0		8	2	0	2	1.43100	28.0
3	1	0	2	2.05200	100.0		9	0	0	4	1.26900	9.0
4	1	1	0	2.00000	84.0		10	-	-	-	1.25400	2.0
5	2	0	1	1.63900	14.0		11	2	1	2	1.16300	18.0
6	1	1	2	1.57200	13.0		12	3	0	0	1.15400	7.0

Stick Pattern
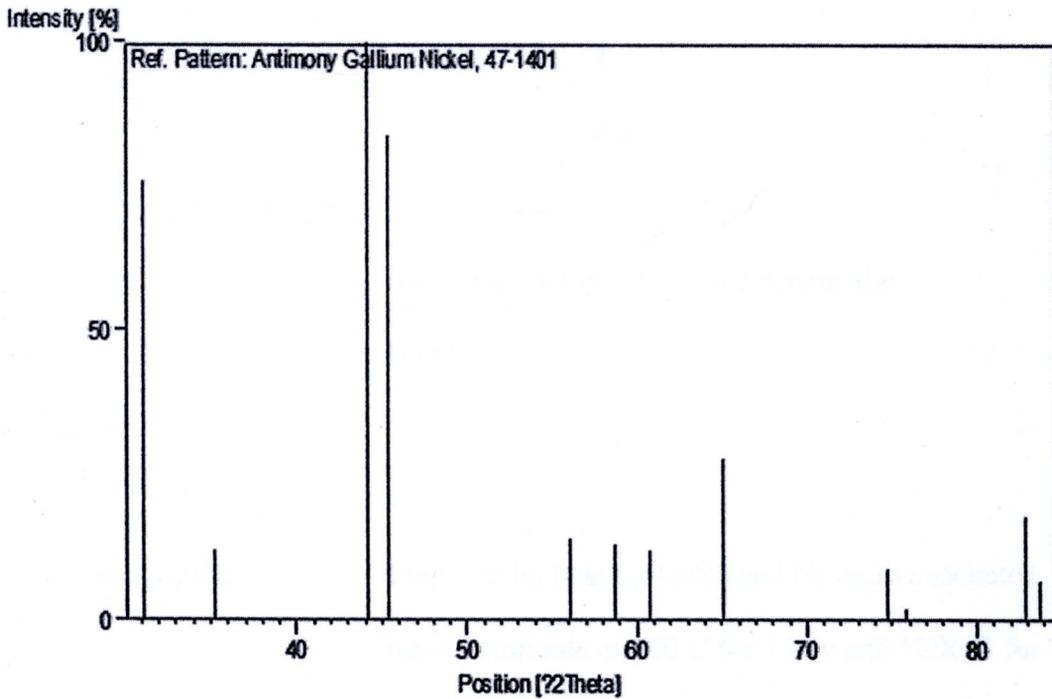
7. Ni₃InSb, JCPDS file number 47-1402

Name and formula

Reference code:	47-1402	Empirical formula:	Ni_3InSb
PDF index name:		Chemical formula:	Ni_3InSb

Antimony Indium Nickel

Crystallographic parameters

Crystal system:	Hexagonal	Alpha (degree):	90.0000
Space group:	P63/mmc	Beta (degree):	90.0000
Space group number:	194	Gamma (degree):	120.0000
a (Å):	4.0000	Measured density:	-
b (Å):	4.0000	Volume of cell:	75.92
c (Å):	5.0900	Z:	1.00
		RIR:	-

Status, subfiles and quality

Subfiles:	Inorganic, Alloy, Metal or Intermetalic
Quality:	Blank (B)

Comments

Color:	-
Sample preparation:	Prepared by heating GaSb and Ni in an evacuated quartz ampoule at 700 C for 1 day and 1200 C for 2 hours, followed by quenching from 700 C.
Melting point:	1,091°C

References

Primary reference:	Jan, C.-H., Chang, Y., *J. Mater. Res.*, **6**, 2660, (1991)

Peak list

No.	h	k	l	d [A]	I [%]
1	1	0	1	2.94600	91.0
2	0	0	2	2.59800	17.0
3	1	0	2	2.09800	91.0
4	1	1	0	2.05700	100.0
5	2	0	1	1.68500	18.0
6	1	1	2	1.61200	16.0
7	1	0	3	1.55500	13.0
8	2	0	2	1.46800	25.0
9	0	0	4	1.30200	11.0
10	2	1	2	1.19300	17.0
11	3	0	0	1.18600	11.0

Stick Pattern

Ref. Pattern: Antimony Indium Nickel, 47-1402
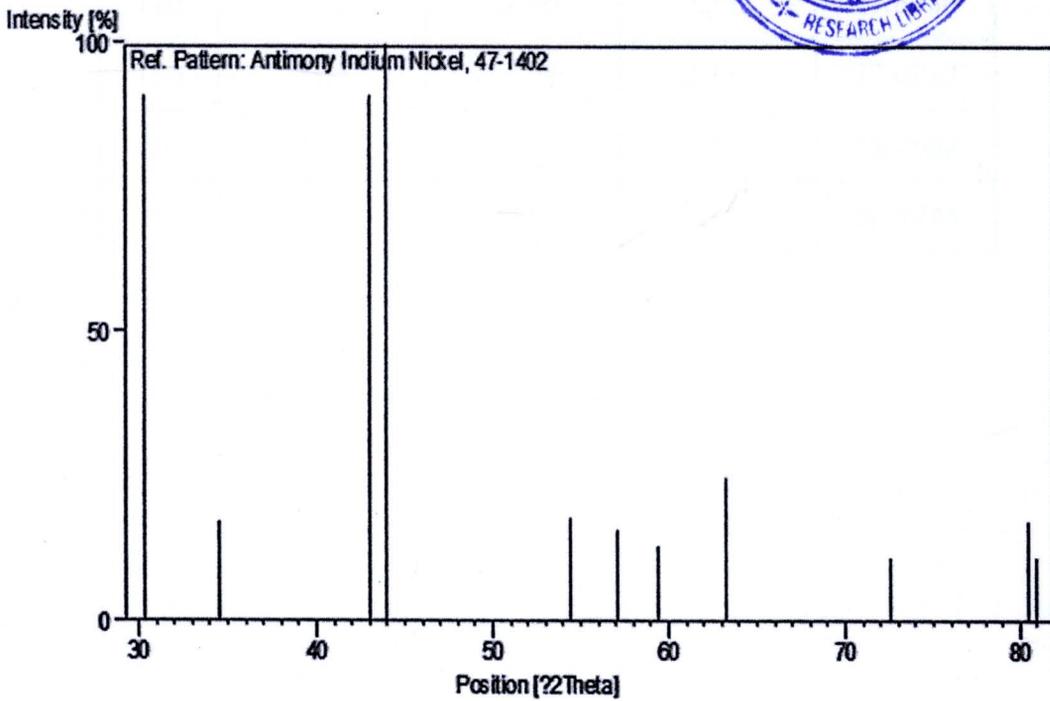
APPENDIX B

Camera constants used for the indexing of SAED pattern

Table B1. TEM constants $(L\lambda)$ at 200 kV

L (cm)	$D_{111}Au$ (mm)	$r_{111}Au$ (mm)	$D_{111}Auv$ (A)	$L\lambda$ (mm.A)
40	8.70	4.35	2.355	10.2442
60	13.2	6.60	2.355	15.5430
80	17.2	8.60	2.355	20.2530
100	21.2	10.60	2.355	24.9630
120	25.2	12.60	2.355	29.6730
150	31.5	15.75	2.355	37.0912
200	41.5	20.75	2.355	48.8662
250	51.8	25.90	2.355	60.9945

APPENDIX C

Microwave induced plasma system

Figure C1. Microwave induced plasma system
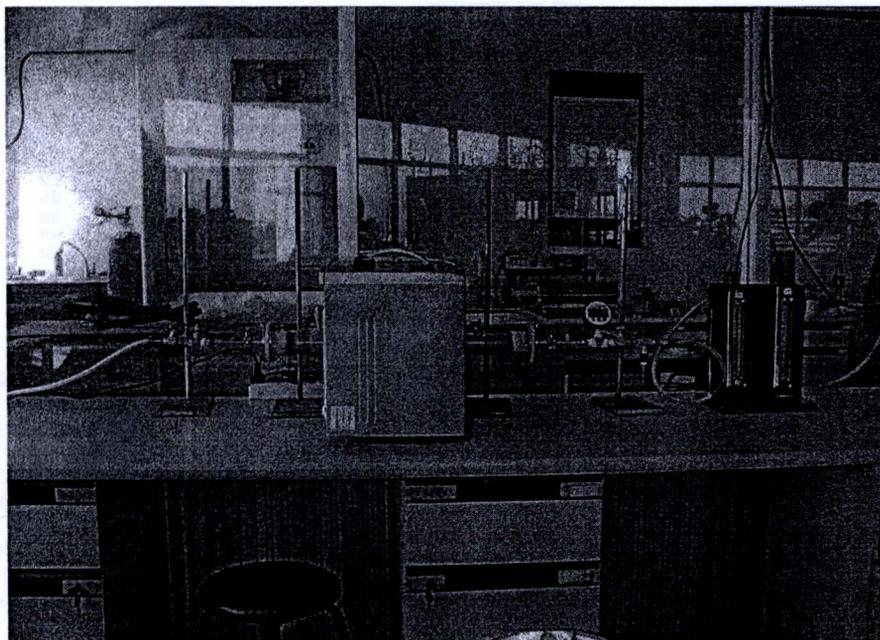
Figure C2.   Microwave induced plasma system during operation
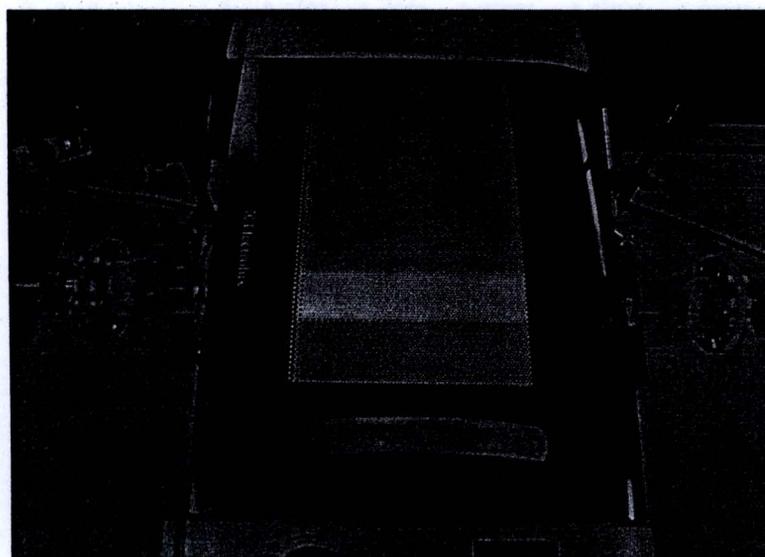
APPENDIX D

The results of the Rietveld refinement analysis

D1. Ni₃GaSb

welcome to the

```
RRRRRRRRRR    IIIIIIII   EEEEEEEEEEEE   TTTTTTTTTTTT   AAAAAAAAAA   NN        NN
RRRRRRRRRRR   IIIIIIII   EEEEEEEEEEEE   TTTTTTTTTTTT   AAAAAAAAAAAA  NNN       NN
RR      RR    II         EE                 TT         AA       AA   NNNN      NN
RR      RR    II         EE                 TT         AA       AA   NN NN     NN
RR      RR    II         EE                 TT         AA       AA   NN  NN    NN
RRRRRRRRRRR   II         EEEEEEEEEEE        TT         AAAAAAAAAAAA  NN   NN    NN
RRRRRRRRRR    II         EEEEEEEEEEE        TT         AAAAAAAAAAAA  NN    NN   NN
RR   RRR      II         EE                 TT         AA       AA   NN     NN NN
RR    RRR     II         EE                 TT         AA       AA   NN      NNNN
RR     RRR    II         EE                 TT         AA       AA   NN       NNN
RR      RRR   IIIIIIII   EEEEEEEEEEEE       TT         AA       AA   NN        NN
RR       RR   IIIIIIII   EEEEEEEEEEEE       TT         AA       AA   NN        NN
```

system for pattern-fitting structure refinement with X-ray and neutron diffraction data

*** Data given by user and system ***

Title: Ni3GaSb

Reliability factors, goodness-of-fit indicator, and Durbin-watson statistic

Rwp = 9.372   Rp = 7.310   RR = 11.355   Re = 5.335   S = 1.7568   d1 = 0.7009   d2 = 0.2701

Ni3GaSb
RB = 2.735   RF = 2.161   E(SCIO) = 2692.07

Lattice parameters (Angstrom or degree) and unit-cell volume (Angstrom**3) in Ni3GaSb

a	b	c	alpha	beta	gamma	V
4.01357	4.01357	5.11362	90.0000	90.0000	120.0000	71.3381
0.00569	-	0.00525	-	-	-	0.1607

Structure parameters, g, x, y, z, B/Angstrom**2, and U/Angstrom**2, in Ni3GaSb
100*B/nm**2   100*U/nm**2

Atom	Site				neq	* g =	n	x	y	z	B	U
Ni	2a	0	0	0	2	0.5000	1.0000	0.00000	0.00000	0.00000	0.500	0.00633
					-	-	-	-	-	-	-	-
Ni1	2a	0	0	0	2	0.5000	1.0000	0.00000	0.00000	0.50000	0.500	0.00633
					-	-	-	-	-	-	-	-
Ni2	2d	1/3	2/3	3/4	2	0.2500	0.5000	0.33330	0.66670	0.75000	0.500	0.00633
					-	-	-	-	-	-	-	-
Ni3	2d	1/3	2/3	3/4	2	0.2500	0.5000	0.66670	0.33330	0.25000	0.500	0.00633
					-	-	-	-	-	-	-	-
Ga	2c	1/3	2/3	1/4	2	0.5000	1.0000	0.33330	0.66670	0.25000	0.500	0.00633
Sb	2c	1/3	2/3	1/4	2	0.5000	1.0000	0.66670	0.33330	0.75000	0.500	0.00633
					-	-	-	-	-	-	-	-

*** Summary of possible reflections (based on the refined parameters) ***

No.	Phase	h	k	l	Code	2-theta	d	Iobs	Ical	|F(nucl)|	|F(magn)|	POF	FWHM	m	Dd/d
1	1	1	0	0	1	25.608	3.47586	1358	474	4.1036	–	0.999	0.1022	6	0.00785
2	1	1	0	1	1	31.086	2.87464	59573	61326	40.4328	–	1.000	0.1820	12	0.01142
3	1	0	0	2	1	35.068	2.55681	9886	9912	45.2042	–	1.002	0.2156	2	0.01191
4	1	1	0	2	1	43.925	2.05960	94253	93504	72.3755	–	1.001	0.2969	12	0.01285
5	1	1	1	0	1	45.144	2.00679	100000	99783	109.1533	–	0.999	0.3363	6	0.01412
6	1	2	0	0	1	52.620	1.73793	150	133	4.7215	–	0.999	0.4035	6	0.01424
7	1	2	0	1	1	55.825	1.64549	12001	11653	33.2367	–	0.999	0.4143	12	0.01365
8	1	1	1	2	1	58.413	1.57861	13610	13572	37.6269	–	1.000	0.4188	12	0.01307
9	1	1	0	3	1	60.440	1.53042	8942	9201	32.0841	–	1.002	0.4181	12	0.01253
10	1	2	0	2	1	64.813	1.43732	24308	25753	57.7947	–	1.000	0.4729	12	0.01300
11	1	2	1	0	1	71.795	1.31375	161	164	5.1075	–	0.999	0.5769	12	0.01391
12	1	0	0	4	1	74.105	1.27841	6415	6524	80.7818	–	1.002	0.5129	2	0.01186
13	1	2	1	1	1	74.512	1.27243	9699	9814	28.8337	–	0.999	0.5803	24	0.01332
14	1	2	0	3	1	78.542	1.21692	4666	4256	27.9793	–	1.001	0.5733	12	0.01224
15	1	1	0	4	1	79.883	1.19983	161	145	5.2165	–	1.002	0.5636	12	0.01175
16	1	2	1	2	1	82.479	1.16852	25364	23207	47.8825	–	1.000	0.6338	24	0.01262
17	1	3	0	0	1	83.340	1.15862	14703	13513	73.6650	–	0.999	0.6919	6	0.01357
18	1	3	0	1	1	85.952	1.12998	0	0	0.0193	–	0.999	0.6941	12	0.01300
19	1	1	1	4	1	91.192	1.07821	22743	21430	68.3769	–	1.001	0.6726	12	0.01150
20	1	3	0	2	1	93.759	1.05532	4017	3795	29.0608	–	0.999	0.7533	12	0.01231
21	1	2	1	3	1	95.510	1.04055	H	5529	24.8839	–	1.000	0.7458	24	0.01182
22	1	2	0	4	1	96.836	1.02980	H	128	5.3509	–	1.001	0.7335	12	0.01136
23	1	2	2	0	1	100.294	1.00339	H	8786	63.0800	–	0.999	0.8938	6	0.01302

*** End of job ***

CPU time = 0 min 0.37 s

--- RIETAN-FP V1.8 Copyright 2009 by F. Izumi ---

D2. Ni$_3$InSb

Welcome to the

```
RRRRRRRRRR      IIIIIIII   EEEEEEEEEEEE   TTTTTTTTTTTT   AAAAAAAAAA   NN        NN
RRRRRRRRRRRR    IIIIIIII   EEEEEEEEEEEE   TTTTTTTTTTTT   AAAAAAAAAAAA  NNN       NN
RR        RR    II         EE                  TT        AA        AA  NNNN      NN
RR        RR    II         EE                  TT        AA        AA  NN NN     NN
RR        RR    II         EE                  TT        AA        AA  NN  NN    NN
RRRRRRRRRRRR    II         EEEEEEEEEE          TT        AAAAAAAAAAAA  NN   NN   NN
RRRRRRRRRRR     II         EEEEEEEEEE          TT        AAAAAAAAAAAA  NN    NN  NN
RR     RRR      II         EE                  TT        AA        AA  NN     NN NN
RR      RRR     II         EE                  TT        AA        AA  NN      NNNN
RR      RRR     II         EE                  TT        AA        AA  NN       NNN
RR       RRR    IIIIIIII   EEEEEEEEEEEE        TT        AA        AA  NN        NN
RR        RR    IIIIIIII   EEEEEEEEEEEE        TT        AA        AA  NN        NN
```

system for pattern-fitting structure refinement with X-ray and neutron diffraction data

*** Data given by user and system ***

Title: Ni3InSb

Reliability factors, goodness-of-fit indicator, and Durbin-Watson statistic

Rwp = 13.677   Rp = 10.206   RR = 16.146   Re = 5.542   S = 2.4679   d1 = 0.5261   d2 = 0.5468

Ni3InSb
 RB = 3.014   RF = 2.793   E(SCIO) =   1785.41

Lattice parameters (Angstrom or degree) and unit-cell volume (Angstrom**3) in Ni3InSb

a	b	c	alpha	beta	gamma	V
4.10655	4.10655	5.18241	90.0000	90.0000	120.0000	75.6860
0.00788	-	0.00722	-	-	-	0.2310

Structure parameters, g, x, y, z, B/Angstrom**2, and U/Angstrom**2, in Ni3InSb
                     100*B/nm**2   100*U/nm**2

Atom	Site				neq	* g =	n	x	y	z	B	U
Ni	2a	0	0	0	2	0.5000	1.0000	0.00000	0.00000	0.00000	1.000	0.01267
						-		-	-	-	-	-
Ni1	2a	0	0	0	2	0.5000	1.0000	0.00000	0.00000	0.50000	1.000	0.01267
						-		-	-	-	-	-
Ni2	2d	1/3	2/3	3/4	2	0.5000	1.0000	0.33330	0.66670	0.75000	1.000	0.01267
						-		-	-	-	-	-
In	2c	1/3	2/3	1/4	2	0.5000	1.0000	0.33330	0.66670	0.25000	2.000	0.02533
						-		-	-	-	-	-
Sb	2c	1/3	2/3	1/4	2	0.5000	1.0000	0.66670	0.33330	0.75000	2.000	0.02533
						-		-	-	-	-	-

neq: multiplicity of the Wyckoff position (number of equivalent points per unit cell)
 n: number of equivalent atoms per unit cell

*** Summary of possible reflections (based on the refined parameters) ***

No.	Phase	h	k	l	Code	2-theta	d	Iobs	Ical	|F(nucl)|	|F(magn)|	POF	FWHM	m	Dd/d
1	1	1	0	0	1	25.018	3.55637	2919	3201	11.7585	-	0.907	0.1688	6	0.01328
2	1	1	0	1	1	30.460	2.93232	91635	92062	52.4736	-	0.990	0.1861	12	0.01193
3	1	0	0	2	1	34.588	2.59120	17416	17426	57.7384	-	1.217	0.1955	2	0.01096
4	1	1	0	2	1	43.161	2.09427	100000	101161	76.2013	-	1.091	0.2209	12	0.00975
5	1	1	1	0	1	44.068	2.05327	95181	95392	117.5072	-	0.907	0.2382	6	0.01027
6	1	2	0	0	1	51.341	1.77819	652	388	8.8612	-	0.907	0.2718	6	0.00987
7	1	2	0	1	1	54.514	1.68193	14686	13512	38.8872	-	0.933	0.2768	12	0.00938
8	1	1	1	2	1	57.196	1.60928	17569	16385	43.3574	-	1.009	0.2785	12	0.00891
9	1	1	0	3	1	59.436	1.55386	14531	12121	36.4571	-	1.145	0.2774	12	0.00848
10	1	2	0	2	1	63.388	1.46616	23881	23298	58.1702	-	0.990	0.3094	12	0.00875
11	1	2	1	0	1	69.928	1.34418	260	262	7.1101	-	0.907	0.3764	12	0.00939
12	1	2	1	1	1	72.601	1.30113	9615	9210	30.5946	-	0.922	0.3778	24	0.00898
13	1	0	0	4	1	72.961	1.29560	6991	6814	79.5969	-	1.217	0.3338	2	0.00788
14	1	2	0	3	1	76.879	1.23905	4531	4235	28.8970	-	1.047	0.3731	12	0.00820
15	1	1	0	4	1	78.510	1.21734	251	227	6.4301	-	1.172	0.3672	12	0.00784
16	1	2	1	2	1	80.418	1.19319	20141	18395	46.0322	-	0.960	0.4138	24	0.00854
17	1	3	0	0	1	81.051	1.18546	11337	10298	71.3306	-	0.907	0.4546	6	0.00928
18	1	3	0	1	1	83.606	1.15561	0	0	0.0192	-	0.919	0.4556	12	0.00889
19	1	1	1	4	1	89.339	1.09571	20036	18240	63.9591	-	1.112	0.4430	12	0.00782
20	1	3	0	2	1	91.214	1.07800	3231	2881	27.7407	-	0.950	0.4981	12	0.00851
21	1	2	1	3	1	93.122	1.06086	4623	4313	23.4645	-	1.006	0.4939	24	0.00816
22	1	2	0	4	1	94.720	1.04713	126	121	5.3608	-	1.091	0.4871	12	0.00783
23	1	2	2	0	1	97.235	1.02664	H	5814	57.9090	-	0.907	0.5991	6	0.00921
24	1	1	0	5	1	101.448	0.99508	H	2052	21.2330	-	1.186	0.5273	12	0.00753

*** End of job ***

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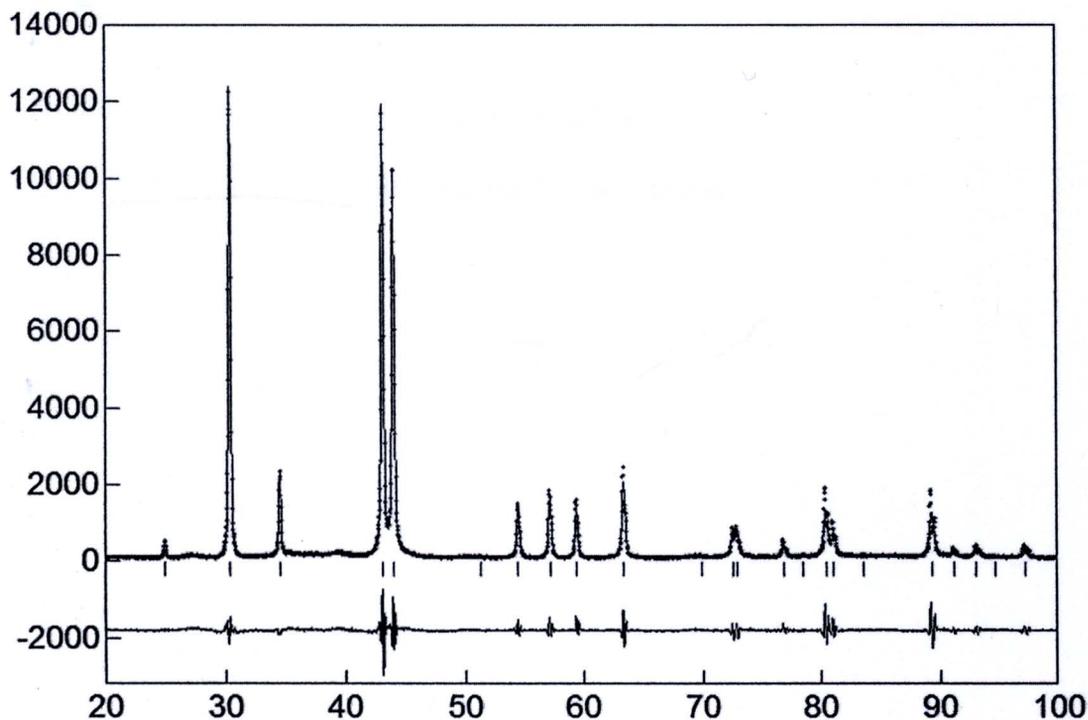
APPENDIX E

International Publications

materials letters

ELSEVIER

Solid-state synthesis of cubic ZnTe nanocrystals using a microwave plasma

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ABSTRACT

Cubic ZnTe nanocrystals were produced from 1:1 and 1.8:1 molar ratios of Zn:Te by a 900 W microwave plasma. The phase was detected using X-ray diffraction (XRD), which are in accordance with those of the simulations, and selected area electron diffraction (SAED). Raman spectroscopy, scanning electron microscopy (SEM) and transmission electron microscopy (TEM) showed that the products were nanocrystals with different orientations, including three longitudinal optical (LO) vibrations at 205, 410 and 620 cm^{-1} and a transverse optical (TO) vibration at 166 cm^{-1}. Their green emissions were detected at 562 nm (2.21 eV) using luminescence spectrophotometry.

1. Introduction

ZnTe is a II–VI semiconducting material which has a 2.26 eV direct wide band gap at 300 K [1,2] and a 6.2 nm exciton Bohr radius [2]. It has a great deal of potential applications: green-light-emitting diodes, solar cells, waveguides, modulators [1], and other optoelectronic and thermo-electric devices [2]. Previously, ZnTe was successfully produced, such as ZnTe nanowires by oriented attachment [2], highly crystalline ZnTe nanocrystals with controlled shape under different growth conditions [3], ZnTe nanowires by the solution–liquid–solid (SLS) mechanism [4], submicrosized ZnTe rods, ZnO/ZnTe cables and ZnTe tubes via exterior-to-interior boron–chalcogen corrosions on the initial ZnO rods [5], single-crystalline ZnTe nanowire arrays by the pulsed electrochemical deposition from aqueous solutions into porous anodic alumina membranes [6], zinc-blende ZnTe nanostructures, periodically twinned nanowires and uniform nanoribbons by hydrogen-assisted thermal evaporation in the presence of Au catalyst via the vapor–liquid–solid (VLS) growth mechanism [7], multilayer superstructures of single-crystalline ZnTe nanowire films through a new growth process: well-aligned ZnTe nanowires congregate into nanowire films [8], and ZnTe powder by a microwave synthesis under 10^{-6} Torr (1.33×10^{-4} Pa) followed by a ZnTe single crystal growth via the vertical Bridgman method [1]. Microwave radiations (2.45 GHz) are coherent and polarized [1]. They are able to couple with atomic materials, and cause them to be heated up very rapidly. In general, materials are classified into three groups: reflectors (bulk metals and alloys), transparencies

(fused-silica and fluoropolymers), and absorbers (inorganic materials, powdered metals, metal oxides and metal halides) [9]. The purpose of the present research was to find the way to save the energy consumption for producing purified ZnTe nanocrystals by a microwave plasma under 4.3 ± 1 kPa argon absolute pressure. This synthetic process required a pressure that is not as low as previously done by Bose et al. [1]. It is inexpensive, shorten reaction time, and environmentally benign.

2. Experiment

To produce ZnTe, Zn and Te powders (purum, analytical grade, Fluka) were used without further purification. Two solid mixtures with 1:1 and 1.8:1 molar ratios of Zn:Te (2 g each) were loaded into silica tubes (11 mm I.D.× 100 mm long), each of which was placed in a horizontal (H) quartz tube. The tube was tightly closed and evacuated to 4.3 ± 1 kPa absolute pressure for removal of air. Subsequently, argon was gradually fed into this H tube. The procedure was repeated three times. Finally, argon in the H tube was evacuated to a constant value of 4.3 ± 1 kPa absolute pressure. Simultaneously, each solid mixture was heated by a 900 W microwave plasma for 10 min, and left to cool down in the vacuum to room temperature. The solid was milled and thoroughly mixed for 5 min. Microwave heating was repeated under the same condition for 10 min at a time, until at the completion of the process. The microwave heating of 1:1 molar ratio products for 10, 20, 30 and 40 min were encoded as A1, A2, A3 and A4, and 1.8:1 molar ratio products for 10 and 20 min as B1 and B2, respectively. The products were then characterized to determine their phase, morphologies, vibrations and emission.

3. Results and discussion

All spectra (Fig. 1a and b) of the products were characterized using XRD and JCPDS database (Reference codes: 15-0746 for ZnTe, 01-1238

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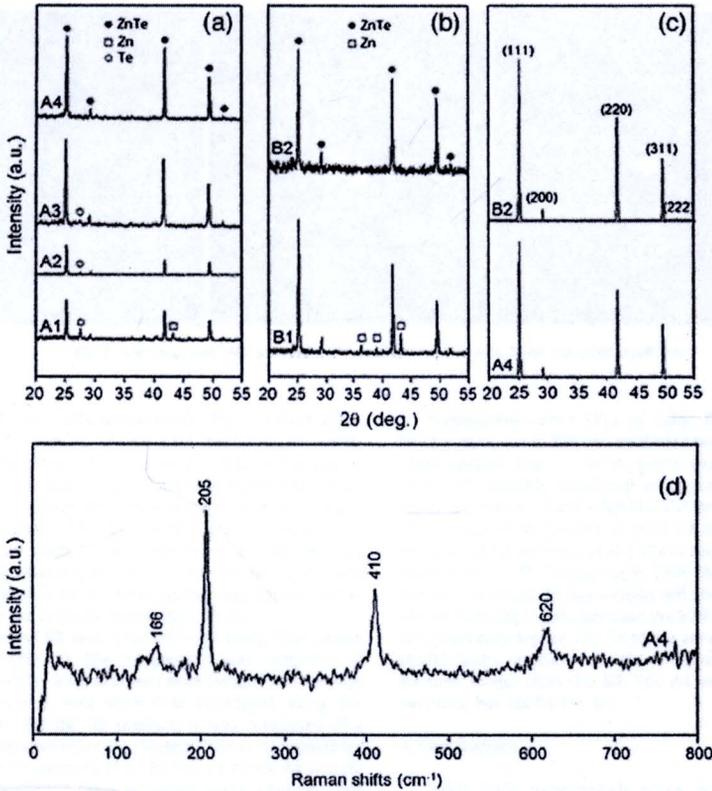
Fig. 1. (a–c) XRD spectra and their simulation, and (d) Raman spectrum of different products.

for Zn and 01-0714 for Te) [10]. At 1:1 molar ratio of Zn:Te and under the 10, 20 and 30 min heating conditions (Fig. 1a), the products (A1, A2 and A3) were composed of ZnTe with some impurities. For 10 min long (A1), both Zn and Te impurities were left in the product. When the reaction time was lengthened to 20 and 30 min, only Te impurity was left in the main products (A2 and A3). No such impurities were detected, when the experimental time was lengthened to 40 min (A4). At the present stage, the chemical reaction of Zn and Te was complete, and only cubic ZnTe was produced as the main product. To save the energy consumption, 1.8:1 molar ratio of Zn:Te (Fig. 1b) was used in the process. ZnTe including some Zn impurity were detected in the product produced under the 10 min heating condition (B1). When the experimental time was lengthened to 20 min (B2), only ZnTe existed as the main products without impurity detection. During the heating process, some of Zn and Te could evaporate as well.

XRD patterns of the A4 and B2 products were also simulated using CaRine Version 3.1 program [11] and Cu–Kα line (0.15406 nm [12]). The results are shown in Fig. 1c. The 2θ diffraction angles and intensities (I) of different crystallographic planes obtained from the experiment, simulation, and the JCPDS database for cubic ZnTe [10] are summarized in Table 1. It is worth noting that these values are in good accordance: simulated patterns for particular conditions were created and used to specify that the experimental patterns could exist in reality, which correspond very well with that of the JCPDS database [10].

Crystallite size (D) of the A4 product was calculated using the (111) peak of its XRD spectrum and the Scherrer's equation [13].

$$D = \frac{K\lambda}{\beta\cos\theta}$$

K is the geometric (shaped) factor which usually takes a value of 0.9 [14,15], λ is the wavelength of Cu K_α radiation (0.15406 nm [12]), and β and θ are the full width at half maximum and Bragg's angle of the (111) peak, respectively. The calculated crystallite size of the A4 product is 77.52 nm.

Table 1
The 2θ diffraction angles (°) and intensities (%) of the JCPDS database for cubic ZnTe, and A4 and B2 products obtained from the experiment (expt.) and simulation (sml.).

Plane	JCPDS		A4 (expt.)		B2 (expt.)		A4 and B2 (sml.)	
	2θ	I	2θ	I	2θ	I	2θ	I
(111)	25.3	100	25.2	100	25.3	100	25.3	100
(200)	29.2	10	29.2	14	29.2	18	29.3	7
(220)	41.8	80	41.9	87	41.9	77	41.9	64
(311)	49.5	35	49.5	53	49.5	61	49.5	38
(222)	51.8	4	51.9	5	51.9	8	51.9	1

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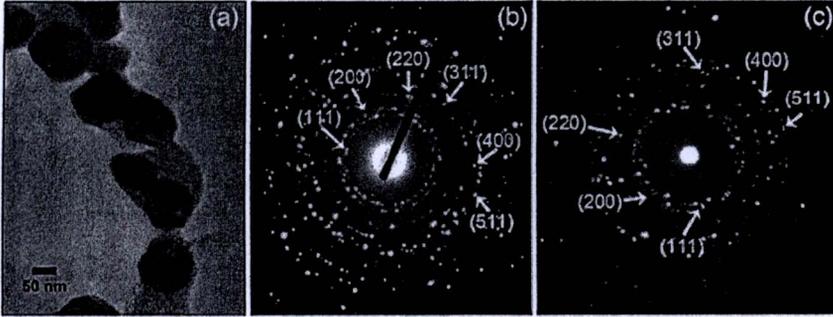
Fig. 2. TEM image and SAED patterns of ZnTe produced under the (a, b) A4 and (c) B2 conditions.

Raman spectrum of cubic ZnTe nanocrystals (Fig. 1d) show three longitudinal optical (LO) modes of 1LO (1st harmonic or fundamental), 2LO (2nd harmonic or 1st overtone) and 3LO (3rd harmonic or 2nd overtone) at 205, 410 and 620 cm^{-1}, and one transverse optical (TO) mode at 166 cm^{-1}, respectively. These Raman shifts are in good accordance with those obtained by Jiang et al. [7], who specified the 1LO, 2LO and TO Raman shifts of ZnTe nanowires at 198, 396 and 168 cm^{-1}, respectively. Comparing to 30 mW He–Ne laser with 632.8 nm (red) wavelength, a great deal of energy was lost during the Raman analysis, due to the inelastic scattering process.

Morphologies of A4 and B2 were characterized using SEM (result not shown) and TEM (Fig. 2). The A4 product was composed of 73.37 nm facet nanoparticles with different orientations. This average size is in accordance very well with that calculated using the Scherrer's equation. But for the B2 product, it was composed of a number of irregular nanoparticles in clusters. These nanoparticles have unclear facets. SAED patterns (Fig. 2b and c) of the A4 and B2 products appear as concentric rings of bright spots, showing that these products were composed of a number of nanocrystals with different orientations. The spaces between adjacent planes were calculated using diameters of the diffraction rings [16], and compared with those of the JCPDS database [10]. The rings for both of these products correspond to the (111), (200), (220), (311), (400) and (511) planes of cubic ZnTe.

Photoluminescence (PL) of cubic ZnTe were studied at room temperature, using 370 nm excitation wavelength from a xenon laser. Their spectra (Fig. 3) were green emission centered at 562 nm (2.21 eV), possibly associated with point defects located at 0.4 eV above the valence band edge [1]. The emission is in accordance with those detected by Jiang et al. (560 nm or 2.21 eV emitted from ZnTe nanowires) [7] and Park et al. (552 nm or 2.25 eV emitted from 14 nm nanocrystals) [3]. Comparing to ZnTe (bulk) with 2.26 eV band gap, the present emission has a slight red shift [7]. It is worth noting that the A4 intensity is stronger than the B2 intensity, due to the difference of crystallinity degree. The A4 atoms are arranged in higher order than the B2 atoms, resulting from the difference in the reaction times — the A4 took longer than the B2. The A4 was composed of facet nanoparticles, but not for the B2.

4. Conclusions

Cubic ZnTe nanocrystals were successfully produced by an inexpensive solid-state synthesis using a 900 W microwave plasma. The phase, nanocrystals, and first three LO and a TO modes for the product with 1:1 molar ratio and 40 min heating were clearly detected. Their photoluminescence was the same green emission centered at 562 nm (2.21 eV), possibly associated with point defects at 0.4 eV above the valence band edge.
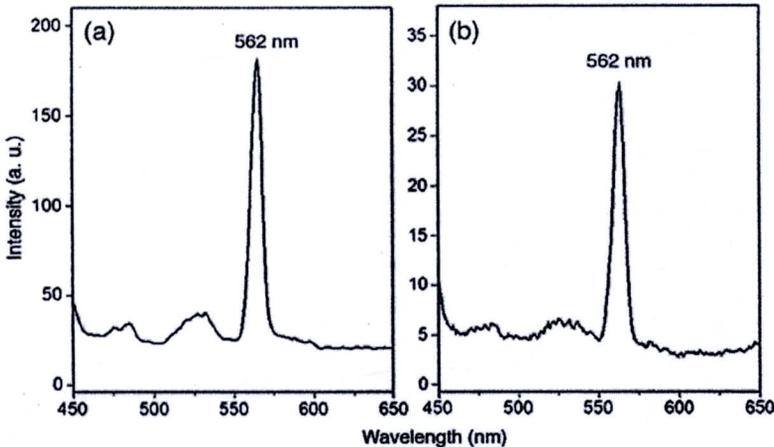
Fig. 3. Photoluminescence of ZnTe produced under the (a) A4 and (b) B2 conditions.

Acknowledgements

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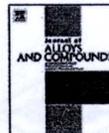
Synthesis and high-temperature thermoelectric properties of Ni₃GaSb and Ni₃InSb

Tawat Suriwong[a], Ken Kurosaki[b,*], Somchai Thongtem[a], Adul Harnwunggmoung[b], Tohru Sugahara[b], Theerayuth Plirdpring[b], Yuji Ohishi[b], Hiroaki Muta[b], Shinsuke Yamanaka[b,c]

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ARTICLE INFO

ABSTRACT

Ni₃GaSb and Ni₃InSb were successfully synthesized by the direct reaction of Ni and GaSb or InSb. The XRD patterns and the lattice parameters of these compounds were in good agreement with the literature data. The Seebeck coefficient (S), the electrical resistivity (ρ), and the thermal conductivity (κ) of Ni₃GaSb and Ni₃InSb were examined in the temperature range from room temperature to 1073 K. Both compounds indicated metal-like characteristics. The power factor ($S^2\rho^{-1}$) values increased with temperature and reached maximum at 1073 K. The κ and the dimensionless figure of merit ZT of both samples increased with temperature. The maximum values of the ZT of Ni₃GaSb and Ni₃InSb were obtained at 1073 K to be 0.022 and 0.023, respectively.

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1. Introduction

The thermoelectric (TE) technology, used for direct conversion of waste heat into electrical power is expected to substantially contribute to future power supply and sustainable energy management [1,2]. The efficiency of a material used in TE devices is determined by the dimensionless figure of merit, $ZT = S^2T/\rho\kappa$, where S, ρ, T, and κ are the Seebeck coefficient, electrical resistivity, absolute temperature, and thermal conductivity. In order to maximize ZT of the material, S is required to be the highest, but ρ and κ are the lowest. Due to their transport property interrelation, they are needed to be optimized to achieve maximum ZT. In recent years, several classes of bulk materials [3,4] with high ZT were discovered, including those found for new TE materials [5,6].

Among the III–V binary semiconductors, gallium antimonide (GaSb) and indium antimonide (InSb) have attracted considerable attention over the last several years. GaSb based binary and ternary alloys have turned out to be important candidates for applications in long wavelength lasers and photodetectors for fiber optic communications [7]. InSb has been interested in high speed applications for transistors and other devices [8,9], which is associated directly with the very low electron effective mass and high mobility [10].

Based on these interesting electrical properties, the TE properties such as S, ρ, and κ of GaSb and InSb have been examined [11–14]. For example, Su et al. investigated the TE properties of Zn-doped InSb single crystals and reported the maximum ZT value to be around 0.27 at 700 K [13]. The TE properties of In₂Te₃–InSb solid solutions were also examined [14]. Ebnalwaled investigated the TE properties of GaSb bulk crystals and reported the power factor value (8.82×10^{-3} mW m⁻¹ K⁻² at 322 K) [11]. However, as for ternary compounds containing Ga, In, and Sb, the TE properties have scarcely reported.

As for M-(Ga or In)–Sb ternary compounds, the existing of Ni₃GaSb and Ni₃InSb have been reported by Jan and Chang [15]. These compounds exhibit the hexagonal, P63/mmc crystal structure – similar to that of Ni₃GaAs [16]. The melting points were determined to be >1339 K and >1364 K for Ni₃GaSb and Ni₃InSb, respectively [15]. However, the physical properties including the TE properties of these compounds are unknown at this moment. In the present study, therefore, we tried to synthesize Ni₃GaSb and Ni₃InSb and investigate the TE properties from room temperature to 1073 K.

2. Experimental

The Ni₃GaSb and Ni₃InSb ternary compounds were synthesized by direct reactions of mixtures of the stoichiometric ratios of Ni (3 N), GaSb (6 N), and InSb (5 N) in sealed silica tubes. These mixtures were processed in a series of steps: preheated at 973 K for 12 h, slowly heated up to 1323 K for 3 days, rapidly cooled to 973 K

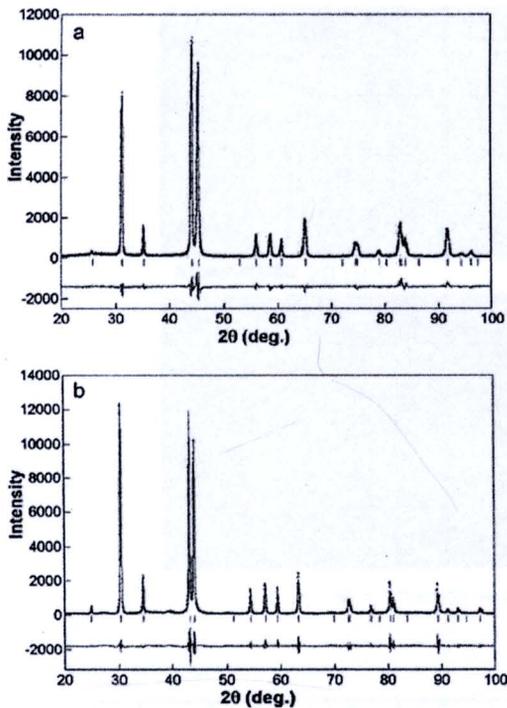Fig. 1. Powder XRD patterns of the polycrystalline samples and the results of the Rietveld refinement of (a) Ni₃GaSb and (b) Ni₃InSb. The experimental data are shown as small red crosses, the calculated fits and the difference curves are shown as blue solid lines. Short vertical lines (green) below the patterns indicate the calculated peak positions. (For interpretation of the references to color in this figure legend, the reader is referred to the web version of this article.)

and held at this temperature for 4 days, and quenched in an ice water bath. The products were crushed and milled into fine powders. Bulk samples were then produced by spark plasma sintering (DR.SINTER LAB, SPS-515A) of the fine powders in a 20 mm diameter graphite die using 40 MPa sintering pressure at 1123 K for 30 min in an argon-flow atmosphere. The ingots were cut into the rectangular shapes of $3\,mm \times 3\,mm \times 15\,mm$ and $10\,mm \times 10\,mm \times 1\,mm$. Their phases, morphologies, and chemical compositions were characterized by a powder X-ray diffraction (XRD) technique using Cu Kα radiation in a step scan condition (fixed time) with an increment of 0.02° and a slit-condition of 1.0°–1.0°–0.60 mm (DS–SS–RS) on Rigaku RINT 2000, and a scanning electron microscope (SEM) equipped with an energy dispersive X-ray (EDX) analyzer (Hitachi, S2600H) at room temperature. The density of the bulk samples was calculated based on the measured weight and dimensions. The electrical resistivity (ρ) and the Seebeck coefficient (S) were measured using a commercially available apparatus (ULVAC, ZEM-1) in a helium atmosphere. Thermal conductivity (κ) was evaluated from thermal diffusivity (α), heat capacity (C_p) and sample density (d) based on the relationship $\kappa = \alpha C_p d$. The thermal diffusivity was measured under vacuum by the laser flash apparatus (ULVAC, TC-7000). C_p was estimated from the Dulong–Petit model, $C_p = 3nR$, where n is the number of atom per formula unit and R is the gas constant. The TE properties were evaluated in the temperature range from room temperature to 1073 K.

3. Results and discussion

The powder XRD patterns of the prepared samples are shown in Fig. 1. Both the samples were identified as Ni₃GaSb and Ni₃InSb, according to the JCPDS database (Reference codes: 47-1401 for Ni₃GaSb and 47-1402 for Ni₃InSb) [15,17], although these compounds contained a few peaks that were inconsistent with the JCPDS data. Therefore, the XRD experimental data were analyzed by the Rietveld refinement [18] on the X-ray diffraction patterns, using
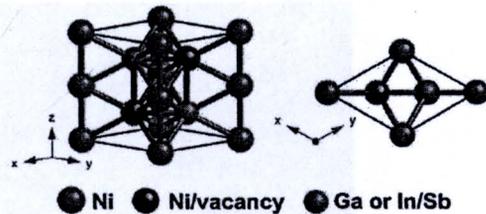
Fig. 2. Crystal structure of Ni₃GaSb and Ni₃InSb.

the hexagonal crystal system with the space group of P63/mmc. Details of the structure are reported in Ref. [15]. Refinement of the patterns for both compounds revealed that all the reflections can be indexed to the Ni₃GaSb and Ni₃InSb phases with no evidence of the impure phases.

The crystal structure of the compounds is described in Fig. 2. According to the crystal structure of Ni₃GaAs [16], Ni atoms occupy the (0, 0, 0) and the (0, 0, 1/2) positions; one vacancy and one Ni atom randomly occupy the (2/3, 1/3, 1/4) and the (1/3, 2/3, 3/4) positions; and Ga and As atoms randomly occupy the (1/3, 2/3, 1/4) and the (2/3, 1/3, 3/4) positions. The results of the Rietveld analysis for Ni₃GaSb and Ni₃InSb were in good agreement with the results of the crystal structure analysis of Ni₃GaAs.

The lattice parameters, sample bulk density, and chemical composition of the samples are summarized in Table 1. The hexagonal lattice parameters and the theoretical density of these compounds were in good agreement with those reported by Jan and Chang [15]. The densities of the polycrystalline samples taken from the sintered specimens for TE characterizations were 96% of the theoretical density. All the samples appeared to be stable in air at room temperature. The quantitative EDX analysis confirmed that the chemical compositions of the bulk sintered samples corresponded to the stoichiometric compositions, as summarized in Table 1.

The SEM and EDX mapping images of the bulk Ni₃GaSb sample are shown in Fig. 3. The SEM image indicated that the sample was homogeneous. The EDX analysis revealed that Ni, Ga, and Sb were uniformly distributed on the sample surface. As for Ni₃InSb, similar results to those for Ni₃GaSb were obtained; i.e. the SEM and EDX analyses confirmed that the Ni₃GaSb and the Ni₃InSb samples were homogeneous with stoichiometric chemical composition.

The temperature dependences of the electrical properties of the Ni₃GaSb and the Ni₃InSb samples are shown in Fig. 4. The electrical resistivity (ρ) of both samples exhibited a metal-like behavior; increased with temperature in the whole temperature range and

Table 1
Lattice parameters, sample bulk density, and chemical composition of Ni₃GaSb and Ni₃InSb.

	Ni₃GaSb	Ni₃InSb
Lattice parameter		
$a = b$ (Å)	4.0135 [4.0000]	4.1111 [4.1100]
c (Å)	5.1136 [5.0900]	5.1882 [5.1900]
Theoretical density		
d_{th} (g cm⁻³)	8.56 [8.65]	8.97 [9.03]
Measured density		
d_{exp} (g cm⁻³)	8.18	8.60
Relative density		
$d_{exp/th} \times 100$ (%)	96	96
Chemical composition determined through the EDX analysis (at.%)		
Ni	59.5	59.9
Ga	20.1	–
In	–	20.0
Sb	20.4	20.1

[], Ref. [15].
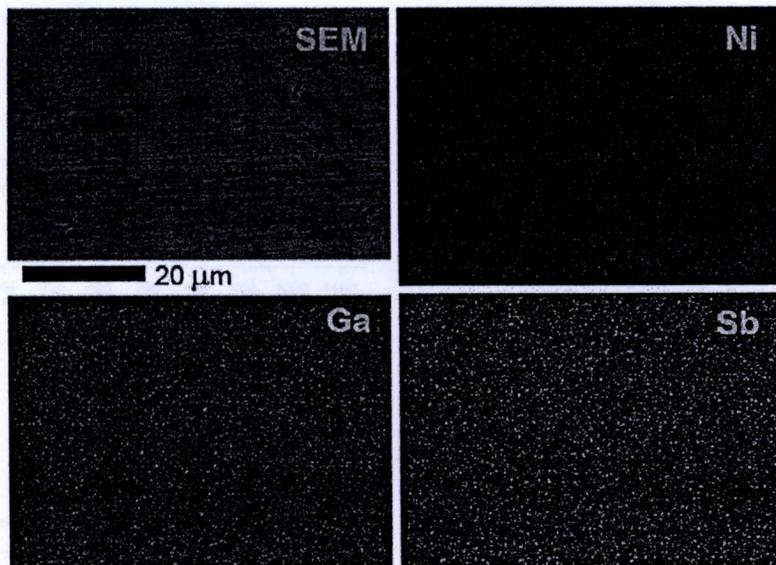
Fig. 3. SEM and EDX mapping images of the Ni_3GaSb bulk sample.
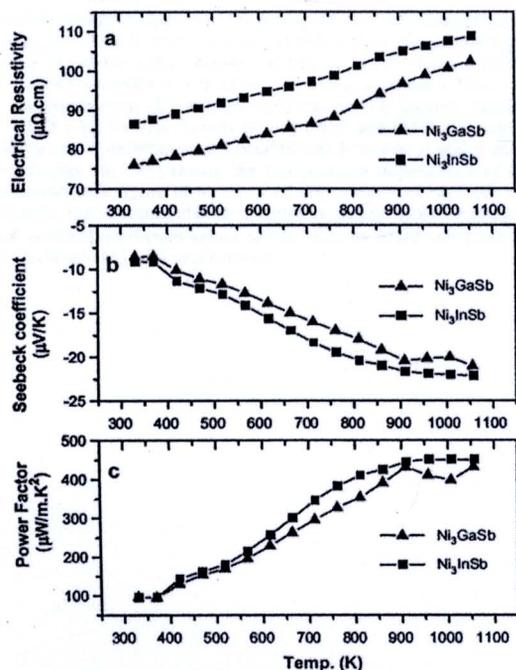

Fig. 4. Temperature dependences of the electrical properties of the polycrystalline samples Ni_3GaSb and Ni_3InSb; (a) electrical resistivity ρ, (b) Seebeck coefficient S, and (c) power factor $S^2\rho^{-1}$.

reached a maximum at 1073 K, as shown in Fig. 4(a). The Seebeck coefficient (S) values were negative for both samples, as shown in Fig. 4(b), indicating that the majority of charge carriers were electrons. The absolute S values of these samples increased with temperature and kept a constant at around 900–1073 K. The absolute S values were quite low like metals; the S values of Ni_3GaSb and Ni_3InSb at 1073 K were −21 and −22 μV K^{-1}, respectively. Ni_3GaSb exhibited the lower ρ and the lower absolute S values than those of Ni_3InSb. Since the larger carrier concentration (n) basically leads to the lower ρ and the lower absolute S, Ni_3GaSb would have the larger n values than that of Ni_3InSb. In order to discuss the magnitude relationship in the electrical properties in more detail, the Hall measurements should be performed. The power factor ($S^2\rho^{-1}$) data of the samples are plotted in Fig. 4(c), as a function of temperature. The power factor was increased with temperature and kept a constant at around 900–1073 K. The maximum values of the power factor of Ni_3GaSb and Ni_3InSb were obtained at 1073 K to be 0.43 and 0.45 mW m^{-1} K^{-2}, respectively. These values were larger than those of the related compounds such as pure GaSb [11] and InSb [12] bulk samples.

The temperature dependence of the thermal conductivity (κ) of the polycrystalline samples of Ni_3GaSb and Ni_3InSb is shown in Fig. 5(a). Unfortunately, the κ values of both samples were quite high like metals and increased with temperature. Ni_3GaSb presented the higher κ values than Ni_3InSb because of the larger electronic contribution on κ of Ni_3GaSb than that of Ni_3InSb. The lattice thermal conductivity κ_{lat} was obtained by subtracting the electronic thermal conductivity κ_{el} from the total (measured) thermal conductivity κ. The value of κ_{el} was calculated using $\kappa_{el} = L\sigma T$, where σ is the electrical conductivity ($=1/\rho$) and L is the Lorentz number ($L = 2.45 \times 10^{-8}$ WΩ K^{-2}). Room temperature values of the κ_{lat} for Ni_3GaSb and Ni_3InSb were 3.2 and 2.3 Wm^{-1} K^{-1}, respectively. These relatively low κ_{lat} of Ni_3GaSb and Ni_3InSb would be caused by their complex crystal structure containing a lot of vacancies as described previously. The heavier molecular weight of Ni_3InSb than that of Ni_3GaSb would lead to the lower κ_{lat} of Ni_3InSb than that of Ni_3GaSb. Note that here the calculated κ_{el}
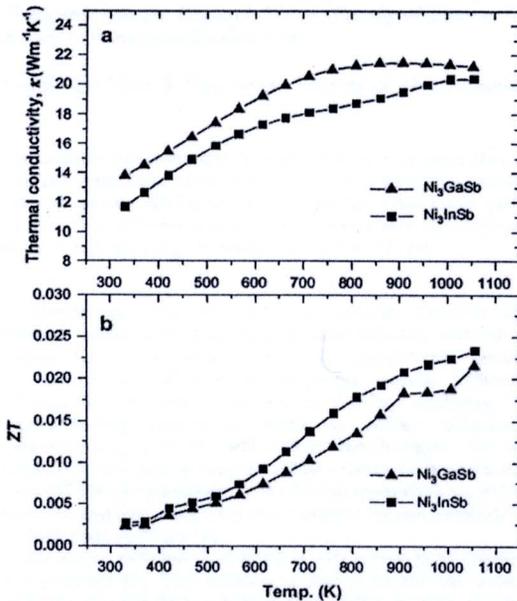
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Fig. 5. Temperature dependences of the (a) thermal conductivity κ and (b) dimensionless figure of merit ZT of the polycrystalline samples of Ni$_3$GaSb and Ni$_3$InSb.

exhibited larger values than the measured κ at high temperatures, i.e. $\kappa_{lat} < 0$. This is likely due to (1) the sample for measuring ρ and κ is not the same sample, i.e. one is 3 mm × 3 mm × 15 mm for ρ measurements, the other is 10 mm × 10 mm × 1 mm for κ measurements; (2) at high temperature the Lorentz number ($L = 2.45 \times 10^{-8}$ WΩ K^{-2}) may be not valid; and (3) there exists a difference in experimental uncertainties between ρ and κ measurements. Fig. 5(b) shows the temperature dependence of the dimensionless figure of merit ZT of the samples of Ni$_3$GaSb and Ni$_3$InSb. The ZT values of both samples increased with temperature and reached maximum values at 1073 K to be 0.022 and 0.023 for Ni$_3$GaSb and Ni$_3$InSb, respectively.

4. Summary

In the present study, Ni$_3$GaSb and Ni$_3$InSb were successfully synthesized and the electrical resistivity (ρ), the Seebeck coefficient (S), and the thermal conductivity (κ) were examined from room temperature to 1073 K. The XRD patterns and the lattice parameters were in good agreement with the previously reported data. The crystal structure was hexagonal with the space group of $P63/mmc$. The ρ of both compounds increased with temperature, indicating a metal-like behavior. The S values were negative for both samples and the absolute values were low (<10 μV K^{-1} at room temperature for both compounds) like metals. Ni$_3$GaSb exhibited the lower ρ and absolute S values than those of Ni$_3$InSb, most likely due to the larger carrier concentration of Ni$_3$GaSb than that of Ni$_3$InSb. The κ and the ZT values of both samples were increased with temperature. The maximum values of the ZT of Ni$_3$GaSb and Ni$_3$InSb were obtained at 1073 K to be 0.022 and 0.023, respectively.

Acknowledgments

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Direct energy gap of Sb$_2$Te$_3$ synthesised by solid-state microwave plasma

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The usefulness of microwave heating and microwave generation of plasma for solid-state synthesis of Sb$_2$Te$_3$ crystals is reported. Lengths of time and molar ratios of Sb:Te were varied to achieve pure products heated by a 900 W microwave-irradiated plasma. In the present research, the products were Sb$_2$Te$_3$ with a rhombohedral crystal system using 2:2, 2:1.75 and 2:1.5 molar ratios of Sb:Te, and lengths of time of 10 and 20 min. Their different crystallographic planes were also detected, including four Raman shifts at 93.9, 102.6, 139.2 and 263.7 cm^{-1}, and direct energy gaps (E_g) in a range of 0.340–0.515 eV.

1. Introduction: Recently, antimony telluride (Sb$_2$Te$_3$) has received considerable attention as a semiconducting material of interest for use in optoelectronic and thermoelectric devices [1, 2], which are influenced by the energy bandgap. Antimony telluride is considered to be one of the best candidates for semiconducting applications based on current technology. Previously, Sb$_2$Te$_3$ crystals with different morphologies were successfully synthesised by chemical solution routes: hexagonal nanoplates by a facile hydrothermal/solvothermal approach [2, 3], and by refluxing synthesis using microwave radiation [4]; and nanobelts by hydrothermal synthesis [5].

Microwave radiation (2.45 GHz) is well known to be coherent and polarised [6]. This radiation is able to couple with atomic materials, causing them to heat up very rapidly. In terms of interaction with microwave irradiation, materials are classified into three groups: reflectors (bulk metals and alloys), transmitting materials (fused-silica and fluoropolymers) and absorbers (inorganic materials, powdered metals, metal oxides and metal halides) [7]. Our motivation here was to investigate the structure and energy bandgap (E_g) of antimony telluride, synthesised by a solid-state microwave plasma process.

2. Experiment: Sb and Te powders (purum, analytical grade, Fluka) for experimental synthesis were used without further purification. Different molar ratios of Sb:Te (2:3, 2:2.25, 2:2, 2:1.75 and 2:1.5) were loaded into 11 mm I.D. × 100 mm-long silica tubes. Each was then placed in a horizontal quartz tube (Fig. 1), which was tightly closed and evacuated to 4.3 ± 1 kPa absolute pressure. Argon was gradually fed into this quartz tube. Evacuation was repeated three times. Finally, each solid mixture was heated by a 900 W irradiated microwave plasma for 10, 20 and 40 min at 4.3 ± 1 kPa absolute pressure, and left to cool down to room temperature.

Products were characterised and recorded on a Philips X'Pert MPD X-ray diffractometer (XRD) equipped with a graphitic monochromator of Cu-K_α radiation ($\lambda = 0.154056$ nm), using a scanning rate of 0.02 deg/s over the 2θ range of 10–60°. Raman vibrations of the products were detected by a HORIBA JOBIN YVON T64000 Raman spectrometer with 30 mW and 632.8 nm (red) wavelength He-Ne laser. Field-emission scanning electron microscopic (FESEM) image was taken by a JEOL JSM-6335F operated at 15.0 kV beam energy. Transmission electron microscopic (TEM) images, and selected area electron diffraction (SAED) patterns were taken on a JEOL JEM-2010, employing at an accelerating voltage of 200 kV. Ultraviolet (UV)-visible spectra were carried out by a Lambda 25 spectrometer using UV lamp with the resolution of 1 nm at room temperature.

3. Results and discussion: XRD spectra (Fig. 2) of the products synthesised using 900 W microwave plasma (at different molar ratios of Sb:Te and lengths of time) were compared with the JCPDS database [8]. At a 2:3 molar ratio of Sb:Te, for 10 and 20 min, the products were Sb$_2$Te$_3$ (JCPDS no. 15-0874) containing some Te residue (JCPDS no. 36-1452). This residue still remained in the product, even after lengths of time as long as 40 min. The amount of Te was reduced in a series of steps until – at 2:2, 2:1.75 and 2:1.5 molar ratios of Sb:Te, with lengths of time of 10 and 20 min – the products were Sb$_2$Te$_3$, without any residual detection. At these stages, Sb and Te had completely combined together chemically to form Sb$_2$Te$_3$ with a rhombohedral crystal system and R-3 m space group [8]. During microwave plasma heating, some of the Sb and Te could evaporate as well.

In the present research, approximate crystallite sizes (L) of Sb$_2$Te$_3$ crystals synthesised under different conditions were calculated using the Scherrer formula [9]

$$L = \frac{\lambda k}{B \cos \theta} \quad (1)$$

where λ, θ, k and B are (respectively): the wavelength of Cu-K_α radiation (0.154056 nm); Bragg angles of the (015) peaks; a

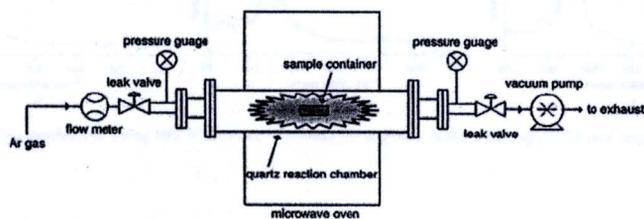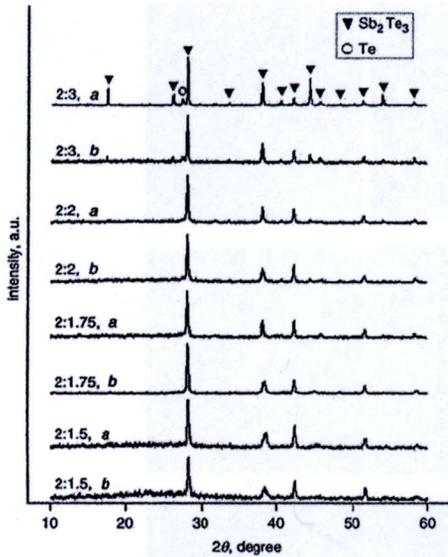Figure 1 *Schematic diagram of the apparatus used for the Sb$_2$Te$_3$ synthesis*

Figure 2 *XRD spectra of the products synthesised using 900 W microwave plasma at different molar ratios of Sb:Te*
a For 10 min
b For 20 min

Table 1 Crystallite sizes, and direct energy bandgaps of Sb_2Te_3 crystals synthesised at different Sb:Te molar ratios and lengths of time by 900 W microwave plasma

Sb:Te molar ratio	Length of time, min	Crystallite size, nm	E_g, eV
2:1.50	10	85.8	0.515
2:1.50	20	110.0	0.515
2:1.75	10	88.8	0.515
2:1.75	20	127.3	0.515
2:2	10	109.2	–
2:2	20	150.1	0.340

To further ascertain the presence of Sb_2Te_3, the products were characterised using Raman spectroscopy. Fig. 3 shows four Raman shifts of Sb_2Te_3 crystals at 93.9, 102.6, 139.2 and 263.7 cm^{-1}. These peaks are in good accordance with those of pure Sb_2Te_3 characterised by Zheng *et al.* [10]. Compared to a 30 mW He-Ne laser with 632.8 nm (red) wavelength, a great deal of energy was lost during Raman analysis, caused by the inelastic scattering process.

SAED patterns (Figs. 4*a*, *b*, *d* and *g*) of the products, synthesised under different conditions, are composed of several concentric rings of diffuse spots caused by the diffraction of transmitted electrons through a number of crystals with different orientations. These interpreted patterns [11] were in accordance with a rhombohedral Sb_2Te_3 crystal system [8]. It should be noted that no detection of Te was found in the SAED pattern for a 2:2.25 molar ratio of Sb:Te and 20 min (Fig. 4*g*), although the residue for this same condition was detected by XRD (result not shown). Its concentration could be too low to be detected by the analysis. A typical example of a SEM image of Sb_2Te_3, produced from a 2:1.5 molar ratio of Sb:Te for 20 min, is shown in Fig. 4*c*. This product is composed of a number of nanocrystals with different orientations. A number of crystallographic planes with different orientations of different products (Figs. 4*e*, *f*, *h* and *i*) were also detected by high-resolution TEM (HRTEM). Their spaces correspond to those of the JCPDS database for a rhombohedral Sb_2Te_3 crystal system [8], showing the presence of crystals with different orientations composing the polycrystalline products. Compared with synthesis by other methods, there are some differences in Sb_2Te_3 products: hexagonal nanoplates by hydrothermal/solvothermal reactions
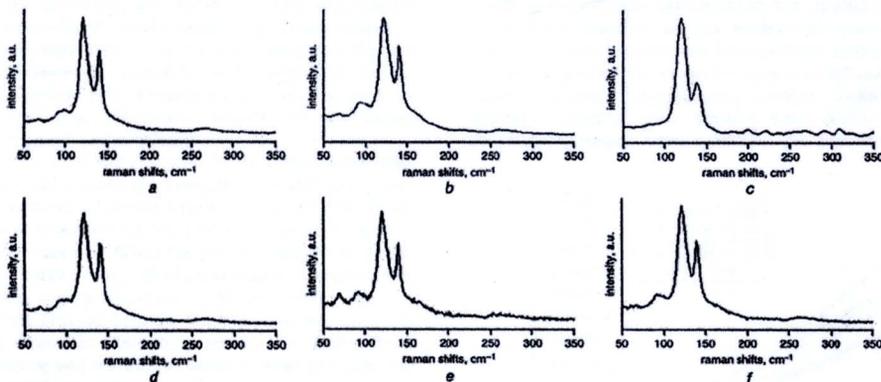
constant (0.90) and full widths at half maximum of the peaks. Calculated crystallite sizes of Sb_2Te_3 crystals synthesised by the 900 W microwave plasma at different molar ratios of Sb:Te and lengths of time are shown in Table 1. The crystallite sizes increased by 28–43% by increasing the lengths of time from 10 to 20 min with the microwave power remaining at 900 W; sizes increased by 27% and 36% by changing the Sb:Te molar ratios from 2:1.50 to 2:2 with the lengths of time remaining at 10 and 20 min, respectively. These results implied that the molar ratios and lengths of reaction time played key roles in the phase and crystallite sizes of Sb_2Te_3 crystals.

Figure 3 *Raman spectra of Sb_2Te_3 synthesised using 900 W microwave plasma for different molar ratios of Sb:Te and lengths of time*
a 2:1.5, 10 min
b 2:1.5, 20 min
c 2:1.75, 10 min
*d* 2:1.75, 20 min
e 2:2, 20 min
f 2:2.25, 20 min
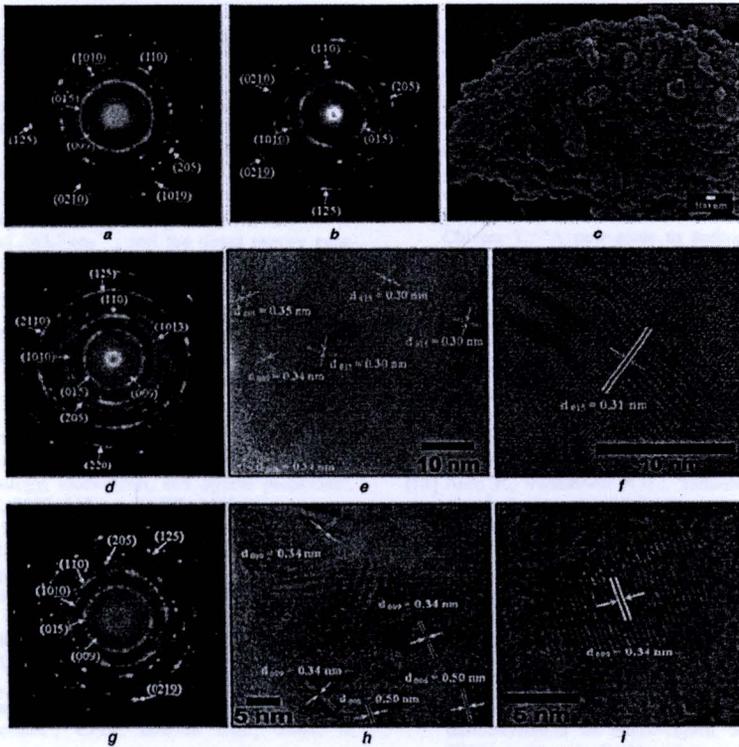
Figure 4 *SAED patterns, and SEM and HRTEM images of Sb$_2$Te$_3$ synthesised using 900 W microwave plasma for different molar ratios of Sb:Te and lengths of time*
a 2:1.5, 10 min
b and *c* 2:1.5, 20 min
d–f 2:2, 20 min
g–i 2:2.25, 20 min

[2, 3], microwave-assisted synthesis [4] and aerosol-assisted chemical vapour deposition [12]; nanobelts by a hydrothermal process [5]; nanowire arrays using a porous anodic alumina membrane as a template by electrochemical deposition [13]; single-crystal nanowires by vapor–liquid–solid method [14]; films produced in a dense plasma-focused device [15]; thermal evaporation [16] and nanostructures (nanowires, nanobelts and nanotubes) by the vapour-transport method [17]. These analyses prove that synthesis methods, starting reagents, pH values, templates and other factors can play roles in product morphologies.

Fig. 5 shows the $(\alpha h\nu)^2$ and $(h\nu)$ plots for the direct allowed transition, where α, h and ν are (respectively) the total absorption coefficient, Planck constant and photon frequency [18–20]. The change of absorption was controlled by two photon energy $(h\nu)$ ranges – the high and low energies. When the photon energy was greater than the energy bandgap (E_g), absorption linearly increased with increasing photon energy. However for photon energy less than E_g, the absorption differed from the linearity; this was caused by the dominant electronic absorption relating to defect levels between the valence and conduction bands of these products. The direct energy bandgaps were determined by extrapolating the linear parts of these curves to $\alpha = 0$, at which the absorption went to zero with a range of 0.340–0.515 eV (as shown in Table 1). These direct bandgaps are in accordance with those in the 0.29–0.46 eV range for Sb$_2$Te$_3$ nanofilms with a thickness between 61.2 nm (35 min deposition) and 4.1 nm (10 min deposition) as determined by Erdoğan and Demir [21], and 0.42 eV

for the 400-cycle Sb$_2$Te$_3$ film (190 nm thick) as determined by Yang *et al.* [22]. In the case of the last product (2:2 molar ratio of Sb:Te for 20 min), the E_g was reduced to be 0.340 eV. Possibly, undetectable impurities/residues existed in the product. These direct bandgaps are the fundamental parameters used to control the optoelectronic and thermoelectric properties of Sb$_2$Te$_3$ crystals. In general, the energy bandgap was influenced by the processing syntheses, morphologies, average crystallite sizes and degrees of structural order–disorder. Some defects could form in the crystalline lattice during synthesis. This promoted the presence
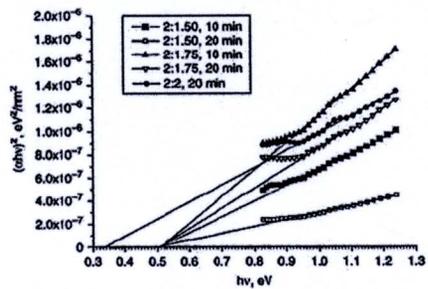
Figure 5 *$(\alpha h\nu)^2$ against (hν) plots of Sb$_2$Te$_3$, synthesised at different Sb:Te molar ratios and lengths of time by 900 W microwave plasma*

of intermediate levels between the valence and conduction bands, which can play a role in the bandgap of the products, as well as in their optoelectronic and thermoelectric properties.

4. Conclusions: Sb_2Te_3 with a rhombohedral crystal system was successfully synthesised by an environmentally benign process with a short reaction time using a 900 W irradiated microwave plasma. At 2:2, 2:1.75 and 2:1.5 molar ratios of Sb:Te, with time lengths of 10 and 20 min, the products were pure Sb_2Te_3 phase with no detection of any residue. Their four Raman shifts were at 93.9, 102.6, 139.2 and 263.7 cm^{-1}, and the direct energy gaps were determined to be 0.340–0.515 eV.

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